



Solid and Hazardous Waste Disposal and Resource Utilization

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Message from the Guest Editors

The scope of this Special Issue includes, but is not limited to, the following:

1. Research on the application of non-thermal plasma and environment-friendly functional material coupling technology in the field of solid waste/hazardous waste thermal treatment and the utilization process;
2. Research on solid waste/hazardous waste disposal, resource utilization and secondary pollution control process technology and industrialization.
3. Research on technologies and management methods related to pollution reduction, carbon reduction and synergistic efficiency in the enterprises, industry and industrial realms.

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Message from the Editor-in-Chief

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